

Notice of References Cited

Application/Control No.

10/809,567

Applicant(s)/Patent Under
Reexamination
CHAO ET AL.

Examiner

Wesley D Markham

Art Unit

1762

Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-6,399,166	06-2002	Khan et al.	428/1.31
	B	US-5,506,706	04-1996	Yamahara et al.	349/117
	C	US-6,522,382	02-2003	Rudin, John Christopher	349/143
	D	US-6,767,594	07-2004	Miroshin et al.	428/1.31
	E	US-2003/0157254	08-2003	Mirkin et al.	427/372.2
	F	US-			
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	O					
	P					
	Q					
	R					
	S					
	T					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Noy et al., "Fabrication of Luminescent Nanostructures and Polymer Nanowires Using Dip-Pen Nanolithography", Nano Letters Vol.2, No.2, pages 109-112, 2002
	V	Piner et al., "Dip-Pen Nanolithography", Science, Vol.283, pages 661-663, January 29, 1999
	W	Hamley, "Nanotechnology with Soft Materials", Angew. Chem. Int. Ed., 42, pages 1692-1712, 2003
	X	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.